



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Koji Nozaki, et al.

P.T. O. Confirmation No. 5544

Serial Number: 09/015,287

Group Art Unit: 1752

Filed: January 29, 1998

Examiner: John S. Y. Chu

For: POLYMER COMPOUND FOR A CHEMICAL AMPLIFICATION RESIST AND
A FABRICATION PROCESS OF A SEMICONDUCTOR DEVICE USING SUCH
A CHEMICAL AMPLIFICATION RESIST

RESPONSE UNDER 37 CFR 1.111

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

February 10, 2004

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Sir:

In response to the Official Action of November 10, 2003, please reconsider the
above-identified application in view of the following remarks:

Remarks/Arguments begin on page 2 of this paper.